



AF ZTW

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Application of:	Peyne et al.	Confirmation No.:	3734
Serial No.:	10/007,134	Art Unit:	2823
Filed:	December 4, 2001	Examiner:	Maldonado, Julio J.
For:	<b>POST ETCH CLEANING COMPOSITION FOR DUAL DAMASCENE SYSTEM</b>	Attorney Docket No.:	060937-0123

**AMENDMENT AFTER FINAL REJECTION**

*enter  
Zell  
09/19/06*  
U.S. Patent and Trademark Office  
Randolph Building  
401 Dulany Street  
Alexandria, Virginia 22314 – **MAIL STOP AF**

Sir:

This Amendment is in response to the Final Office Action dated July 5, 2006 for the above identified patent application.

**Amendments to the Claims** are reflected in the listing of claims, which begin on page 2, and,

**Remarks** being on page 12 of this Amendment.